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Electroanalysis and speciation of trace inorganic arsenic in natural waters with ensembles of nanoelectrodes

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OUTLINE

1. Introduction:
preparation and characteristics of
ensembles of nanoelectrodes (NEEs)
2. Trace electroanalysis of As with NEEs:
 - NEEs vs Conventional Gold Electrodes
 - Speciation of inorganic Arsenic.
3. From 2D to 3D-NEEs
4. Methods and devices for analysis of real samples
5. Conclusions and prospects



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OUTLINE

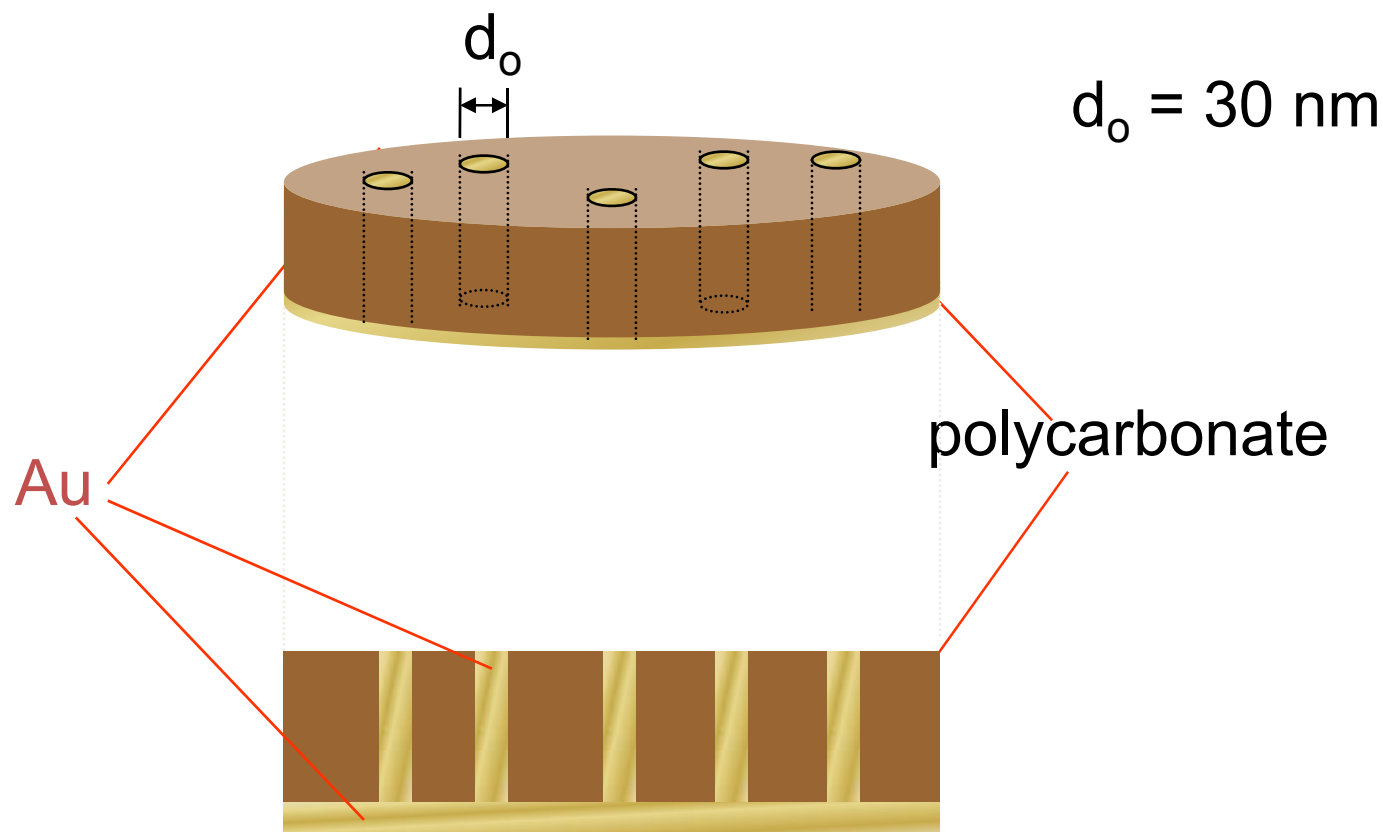
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NEE= Nano Electrode Ensemble



Menon & Martin, *Anal.Chem.*, 67 (1995) 1920, Ugo et al., *Anal.Chem.*, 68(1996) 4160

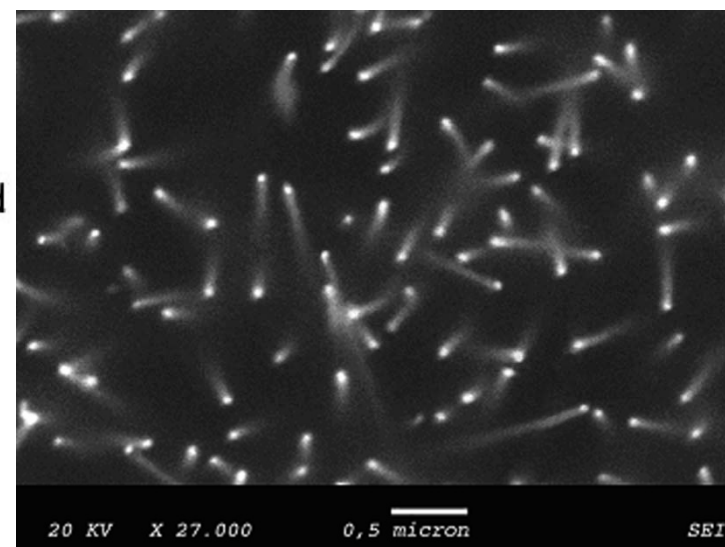
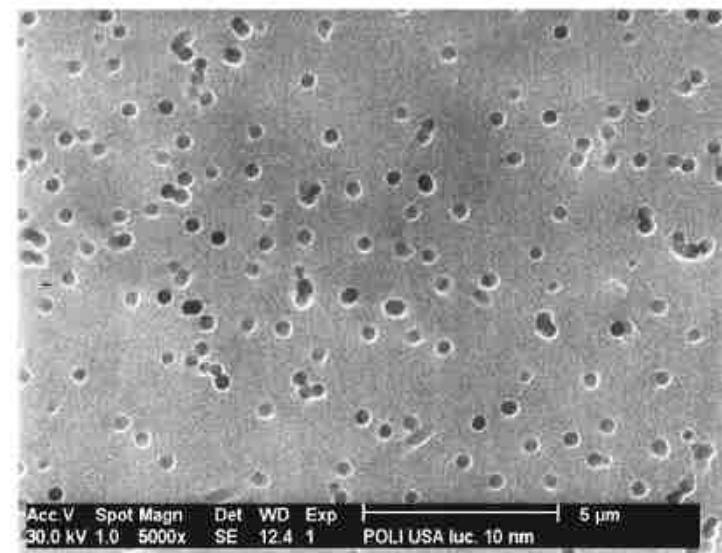
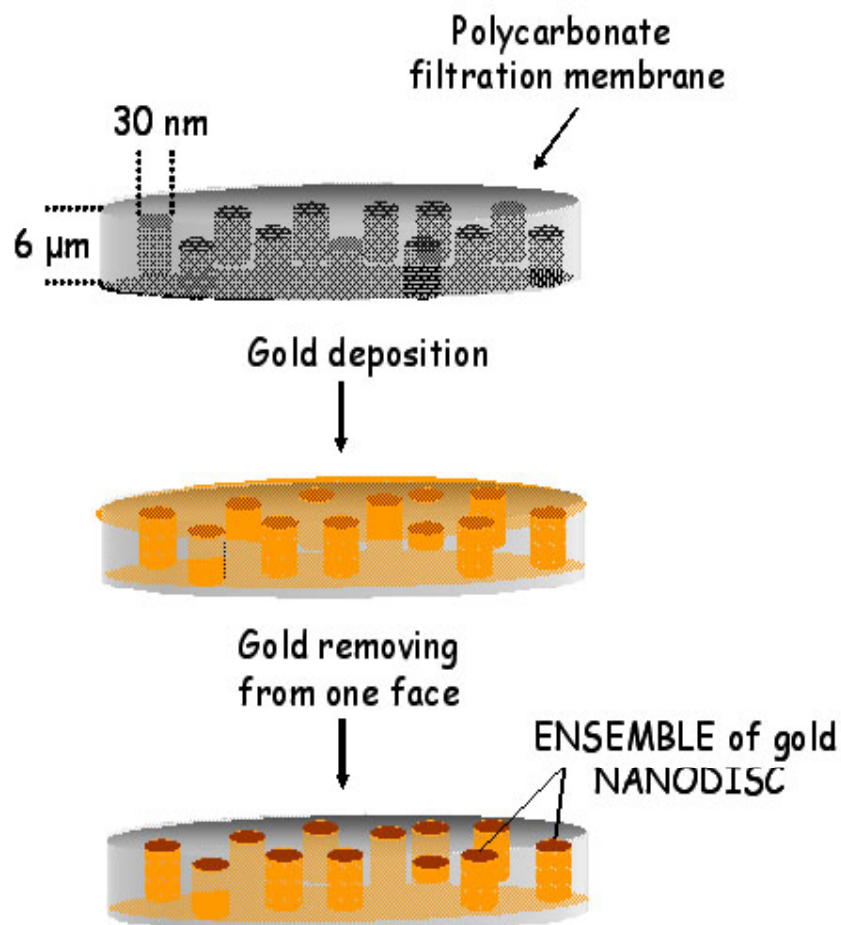
For reviews see: Ugo & Moretto in *Handbook of Electrochemistry*, C. Zoski ed., Elsevier 2007 and in *Handbook of Electrochemical Nanotechnology*, 2009



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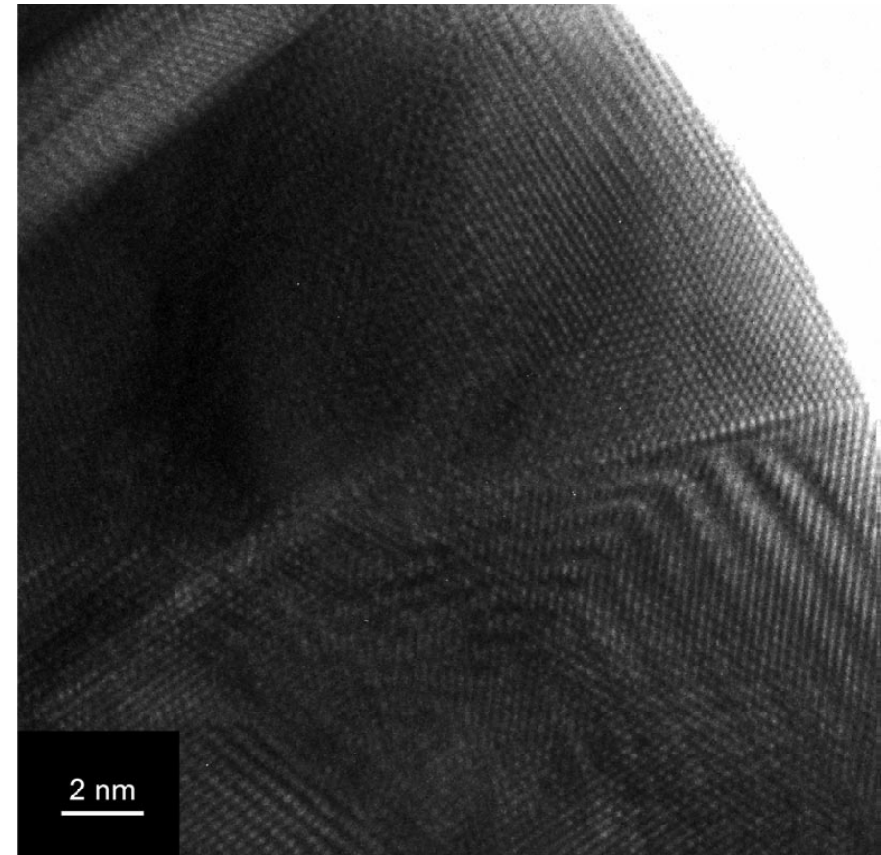
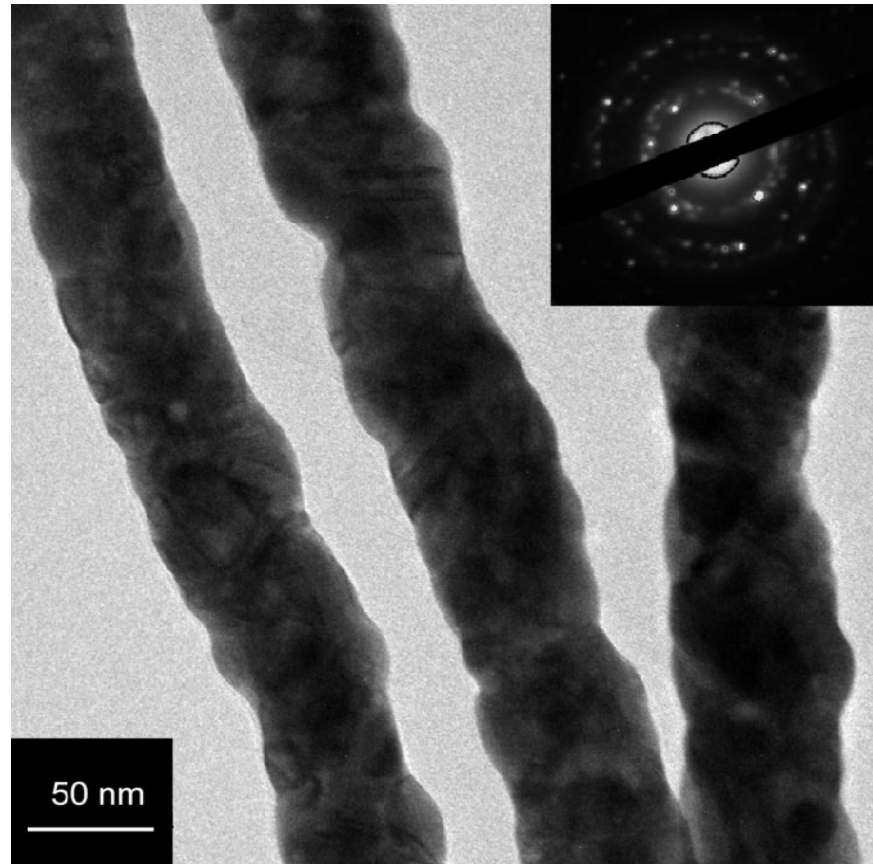
Template deposition of NEE



Menon & Martin, *Anal.Chem.*, **67**
(1995) 1920



HR-TEM after 24 h Au electroless plating at pH 12

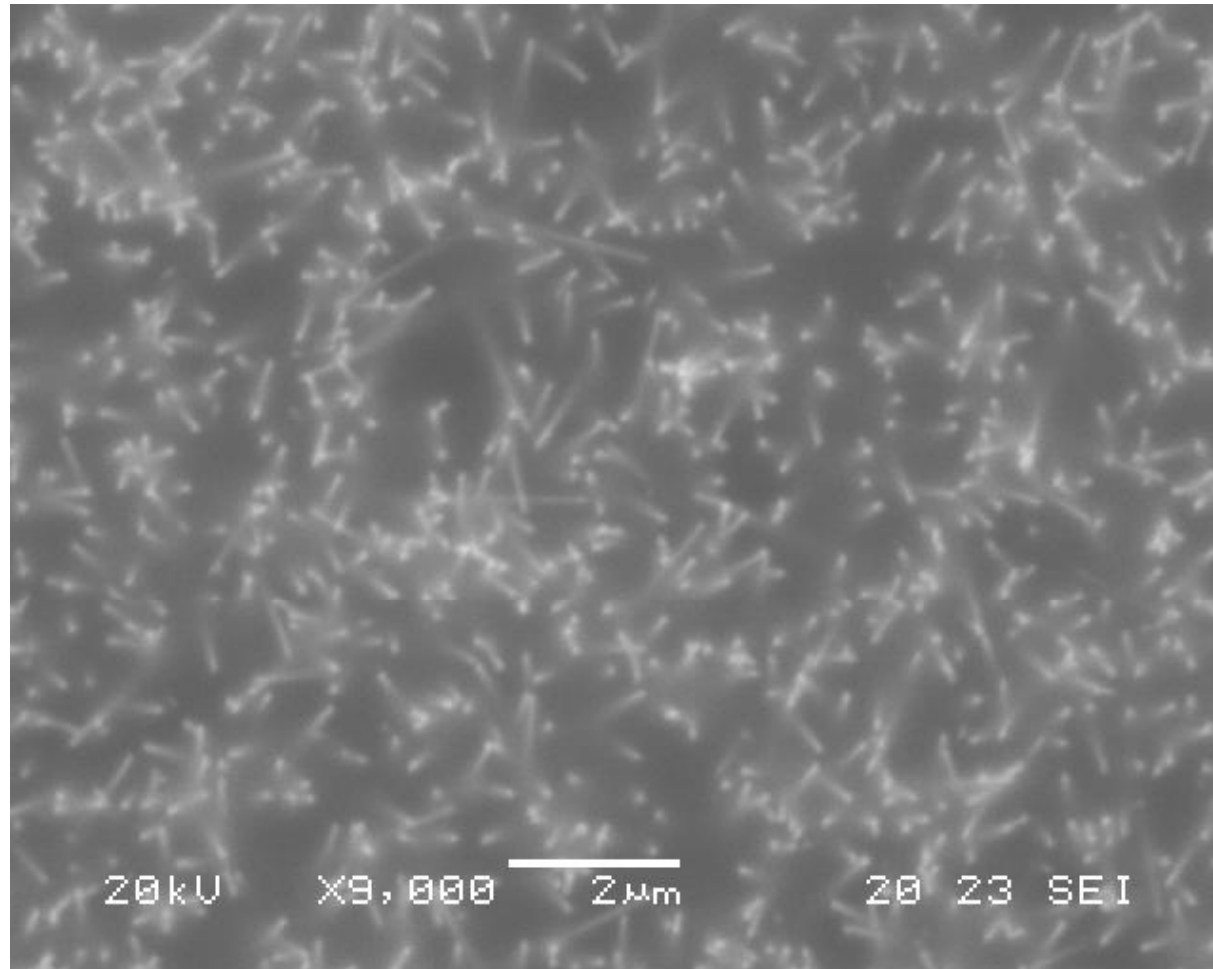




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SEM image of NEE (30nm)

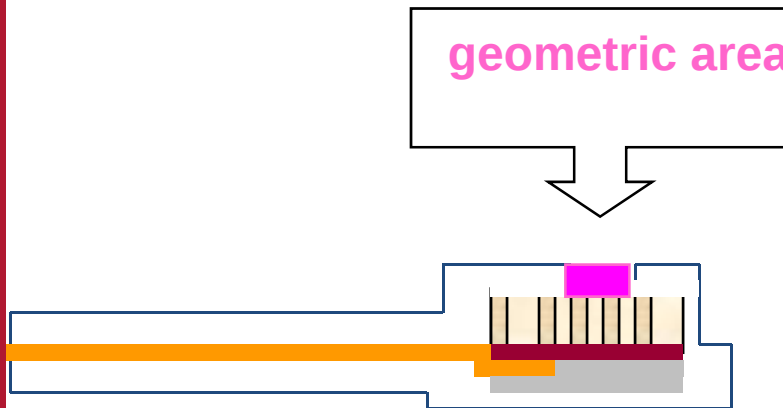




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Fabrication of the ensemble

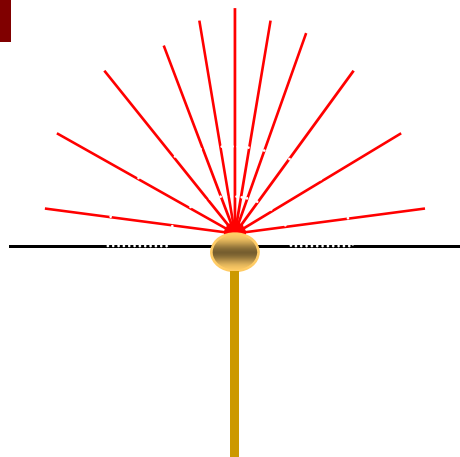


$$\text{Active area} = \sum A_i$$

$$\text{Fractional Area} = \frac{A_{\text{active}}}{A_{\text{geo}}}$$

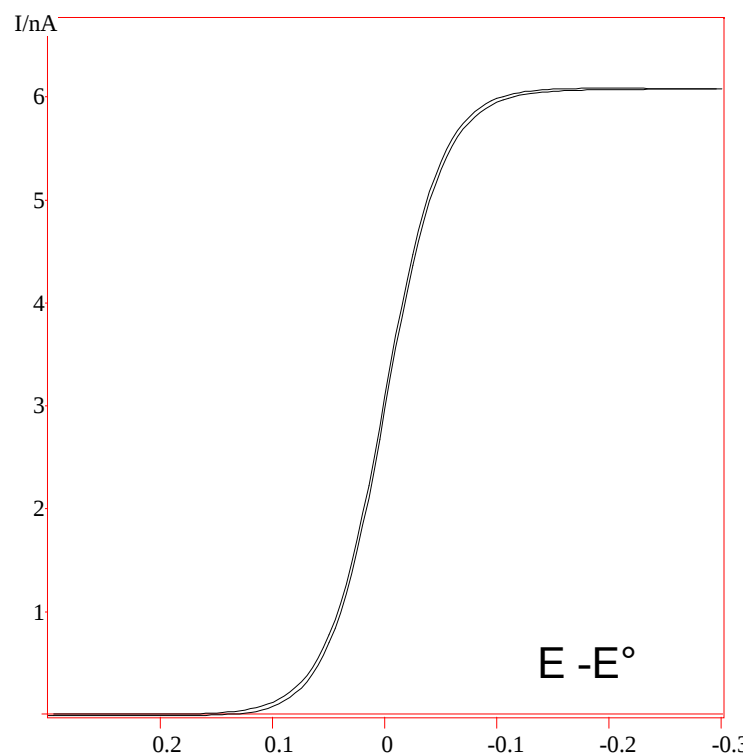
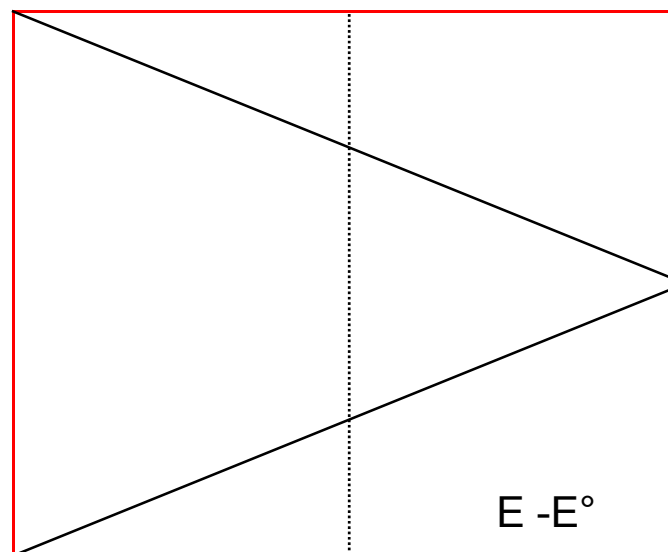


Voltammetry at NEE



Hemi-spherical
diffusion at ultramicro-
electrodes
(steady state)

$$I_l = 4nFD C_r \quad (\text{microdisc})$$





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Enhanced mass transport at nanoelectrodes

$$1/\delta(t) = [1/(\pi Dt)^{1/2}] + 1/r \quad (1)$$

where :

- δ is the thickness of the diffusion (depletion) layer,
- D is the diffusion coefficient of the analyte,
- t is the time scale of the experiment
- r is the radius of the electrode

As the electrode decreases in size, the depletion layer thickness approaches the size of the electrode dimension

$$I(t \rightarrow \infty) = nFAC^* / \delta(t \rightarrow \infty) \quad (2)$$

Where:

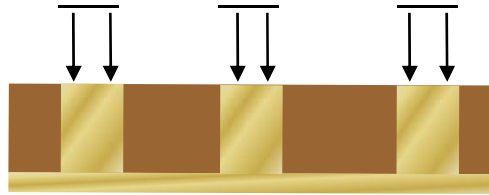
- n is electron stoichiometry;
- F is faraday constant;
- A is the electrode surface area;
- C^* is the bulk concentration of the analyte

Smaller electrode provides higher current density

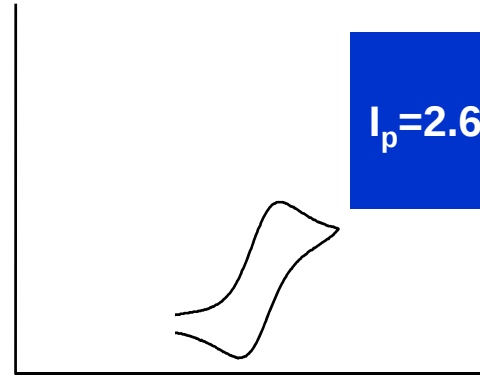


X↑

LINEAR ACTIVE



I

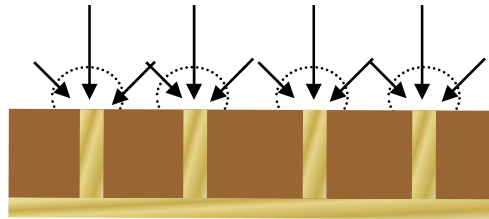


$$I_p = 2.69 \times 10^5 n^{3/2} A_{\text{act}} v^{1/2} D^{1/2} C$$

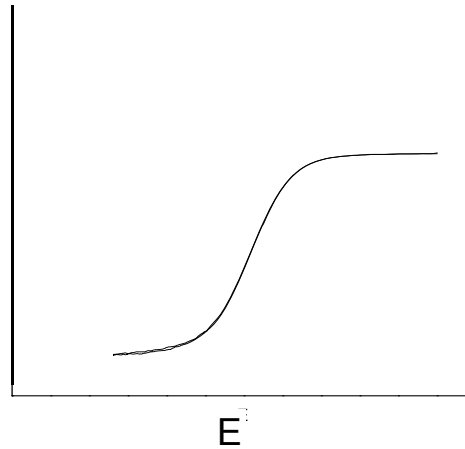
E

X↑

PURE RADIAL



I

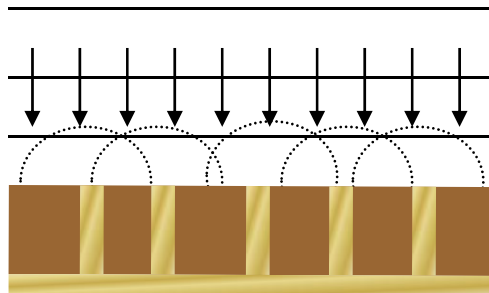


$$I_{\text{lim}} = 4nFDCA_{\text{geom}}q$$

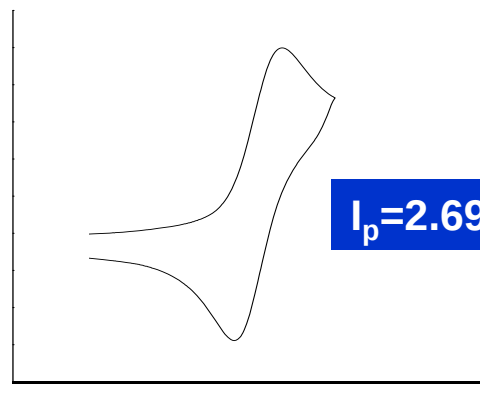
E

X↑

TOTAL OVERLAP



I



$$I_p = 2.69 \times 10^5 n^{3/2} A_{\text{geom}} v^{1/2} D^{1/2} C$$

E



SIGNAL TO BACKGROUND RATIO

At NEE (total overlap regime):

Faradaic current: $I_p = 2.69 \times 10^5 n^{3/2} A_{\text{geom}} v^{1/2} D^{1/2} c_b$

Background (charging) current : $I_c = A_{\text{active}} v C_d$

At conventional electrodes:

Faradaic current: $I_p = 2.69 \times 10^5 n^{3/2} A_{\text{geom}} v^{1/2} D^{1/2} c_b$

Background (charging) current: $I_c = A_{\text{geom}} v C_d$

$$(I_p/I_c)_{\text{NEE}} = (I_p/I_c)_{\text{conv}} \times (A_{\text{geom}}/A_{\text{active}}) = \frac{(I_p/I_c)_{\text{conv}}}{\frac{A_{\text{active}}}{A_{\text{geom}}}}$$

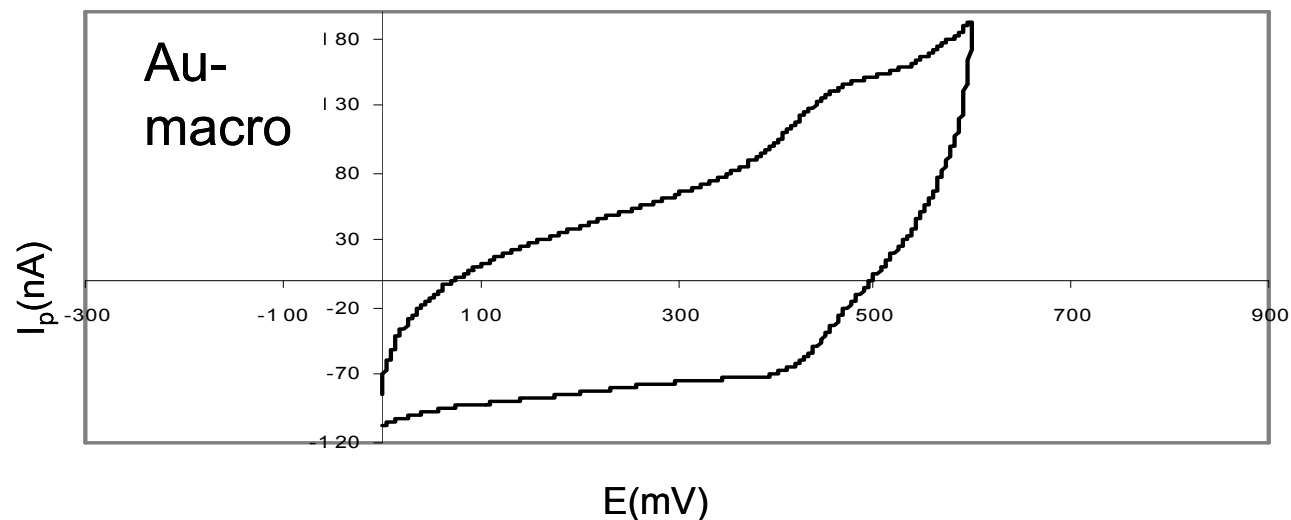
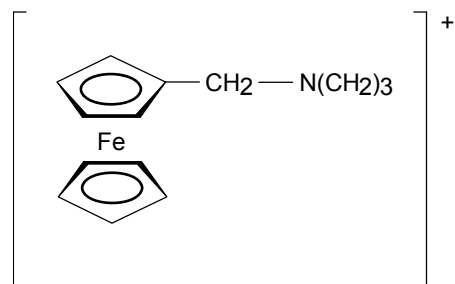
$$F = 0.1-2.5 \times 10^{-2}$$

Fractional electrode
area



LOWERING OF CAPACITIVE CURRENT AT NEE

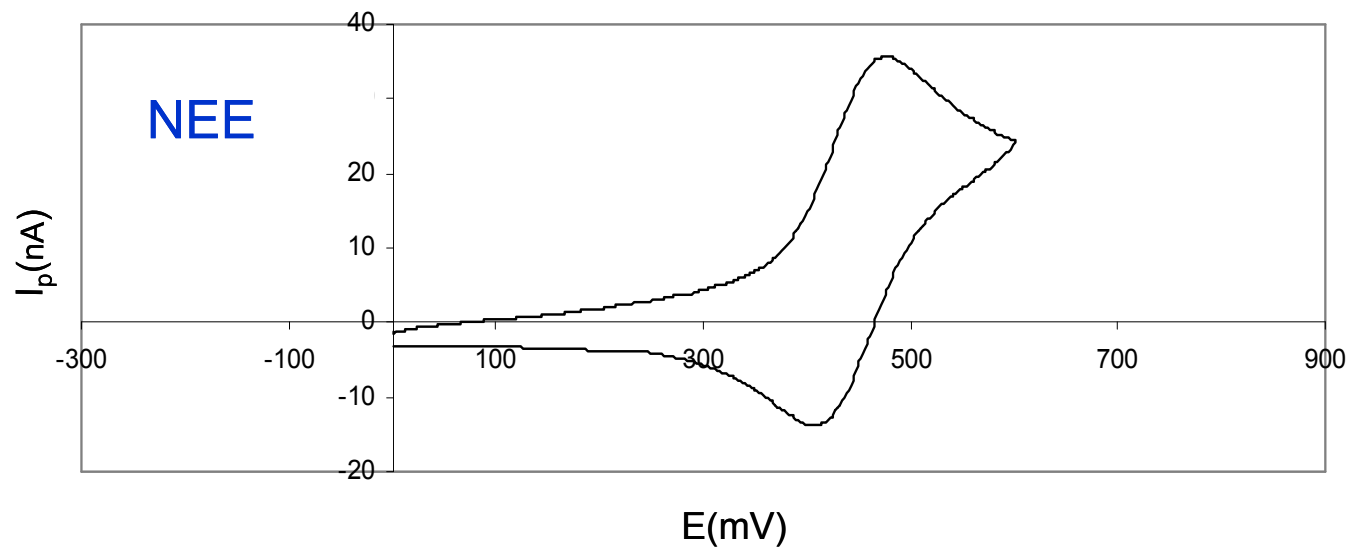
5 μM FA⁺, 1 mM NaNO₃, A_{aeom} 0.07 cm², 20 mV/s



DL at NEE:

Ugo et al.
Anal. Chem.
68 (1996) 4160

Brunetti et al.
J. Electroanal. Chem.
2000, 491(2000)
166





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IMPROVING DETECTION LIMITS WITH NEE

Analyte	DETECTION LIMITS	
	Macro Au	NEE
FA ⁺	$2 \times 10^{-5} \text{ M}$	$5 \times 10^{-8} \text{ M}$
[Ru(NH ₃) ₆] ³⁺	$2 \times 10^{-5} \text{ M}$	$7 \times 10^{-8} \text{ M}$
Azure A	$2.4 \times 10^{-6} \text{ M}$	1.2×10^{-7}
MV ²⁺	$1 \times 10^{-5} \text{ M}$	$2 \times 10^{-6} \text{ M}$
Cytochrome c	$2.4 \times 10^{-5} \text{ M}$	$1.2 \times 10^{-6} \text{ M}$
Iodide	$4 \times 10^{-6} \text{ M}$	$3 \times 10^{-7} \text{ M}$

Brunetti et al. *J.Electroanal.Chem.*, 491 (2000) 166

Ugo et al. *Talanta*, 62 (2004) 1055

F.C.Pereira et al. *Anal. Chim. Acta* 575 (2006) 16-24



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Arsenic analysis: goals

The development of sensitive and disposable devices for the decentralized analysis of inorganic As(III) and As(V) in water samples, achieving $DL < 10 \mu\text{g/L}$ (WHO recommended limit)



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Steps

- Evaluate the performances of NEEs (vs Macro Gold Electrodes) in anodic stripping voltammetry of As(III).
- Speciation of total inorganic Arsenic
- Etching from 2D to 3D-NEEs
- Analysis of real samples



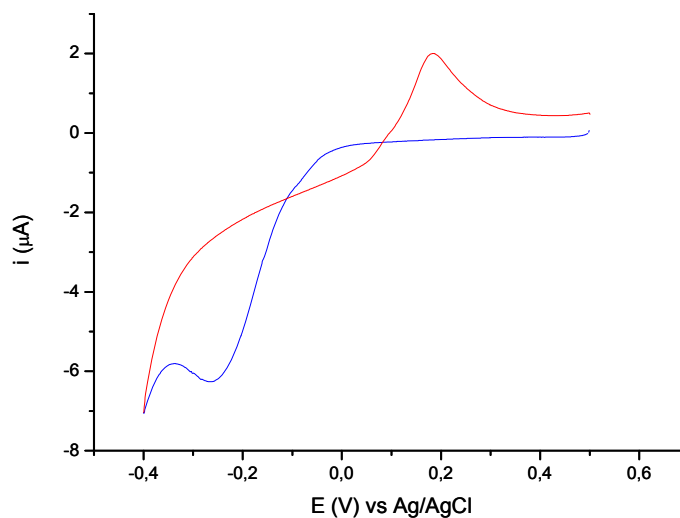
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Principles of Anodic Stripping Voltammetry of As on Au electrodes

DEPOSITION STEP: $\text{As}^{3+} + 3\text{e}^- \longrightarrow \text{As}^0$

STRIPPING STEP: $\text{As}^0 \longrightarrow \text{As}^{3+} + 3\text{e}^-$



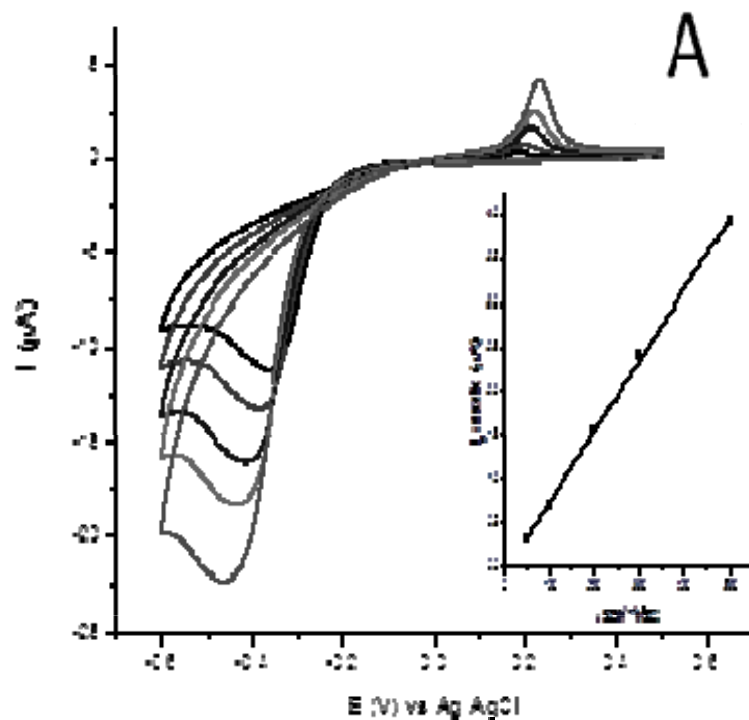
CV recorded at a Macro Gold Electrode in 1M HCl, 2 g/L hydrazine and $5 \mu\text{gL}^{-1}$ As(III)



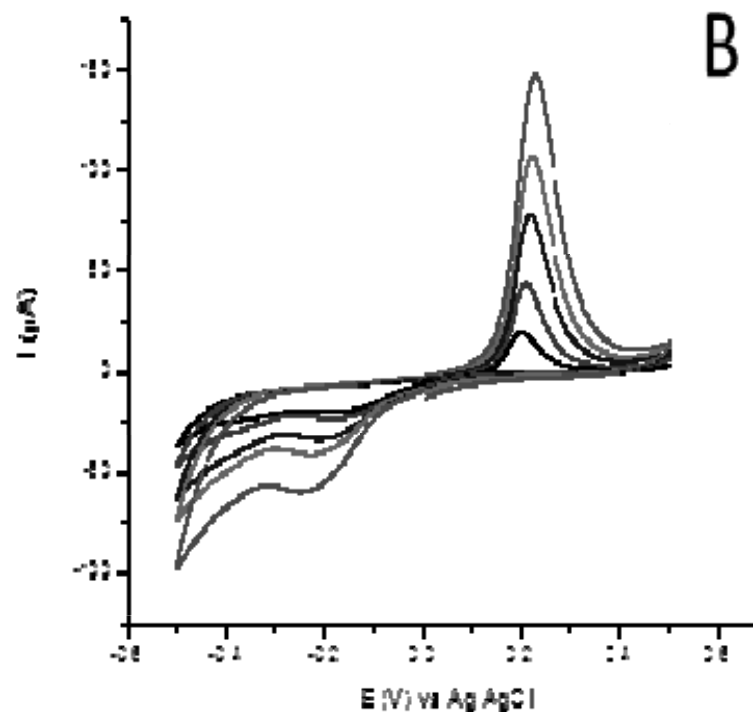
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NEE



Au-macro



Cyclic voltammograms recorded at different scan rates (from 0.05 to 0.5 V/sec) at a NEE (A) and at a flat gold electrode (B) in solution of 40 μgL^{-1} As(III) in HCl 0.2M.

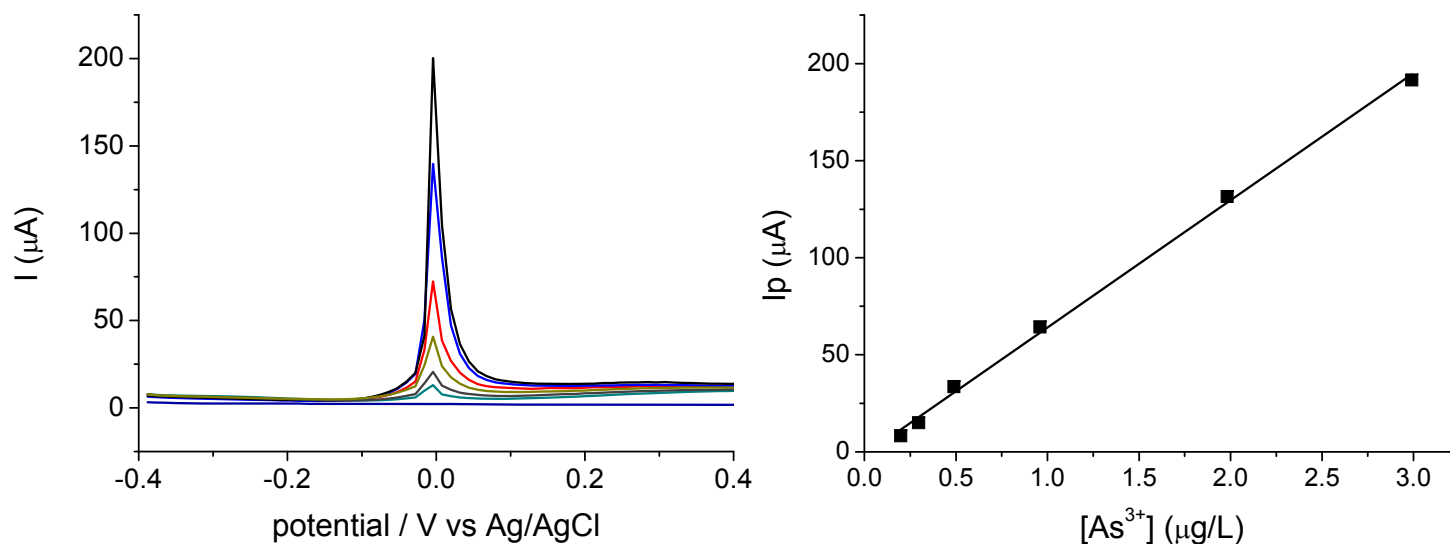
Inset: i_p vs scan rate.



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AS-SWV of As(III) at NEE



SW-ASV parameters: incr 12mV; amplitude 75mV; frequency 250Hz.

Analytical procedure:

- Deposition at -0.4 V for 180s
- Stripping between -0.4 and 0.4V
- Cleaning step: 0.5 V for 60 s

Electrolyte concentration:

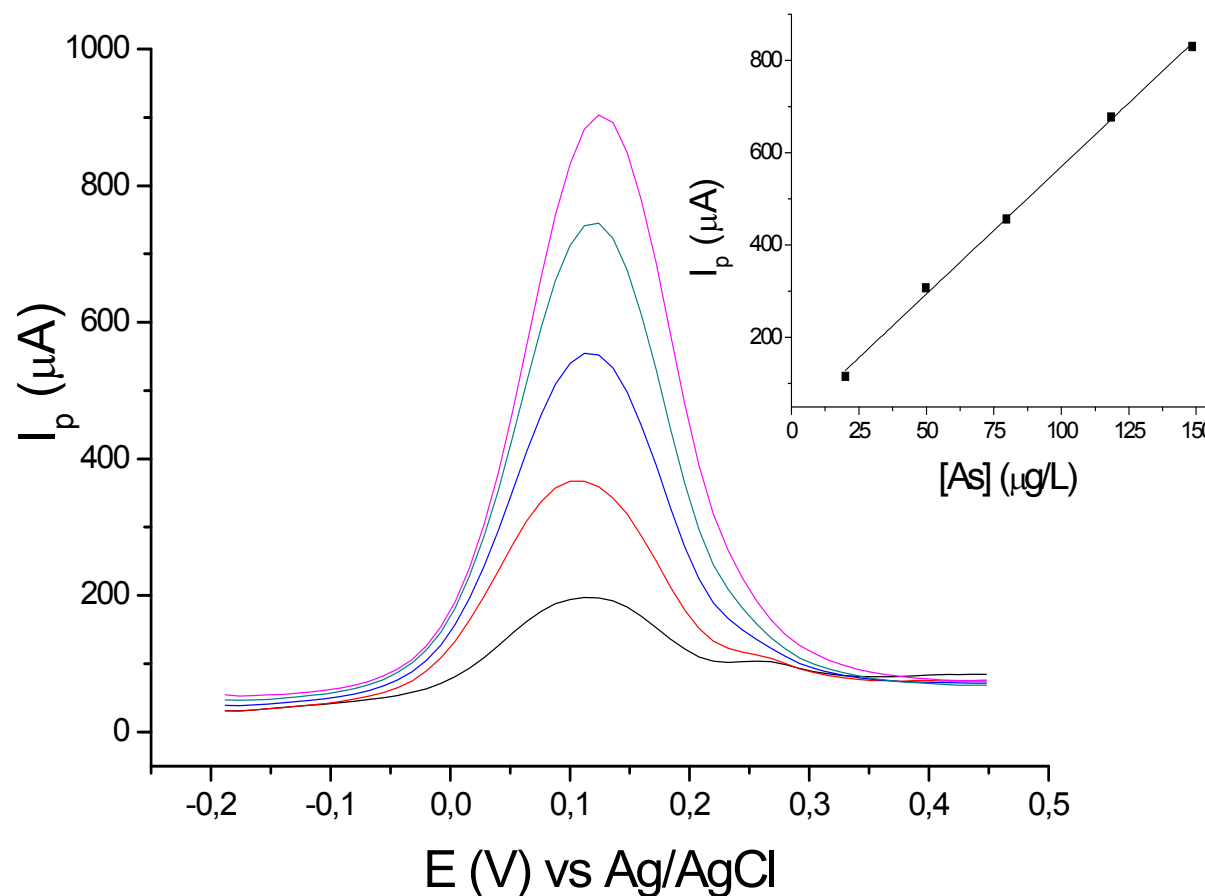
- o HCl 0.2 M
- o Hydrazine 62 mM (2 g/L)



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Anodic stripping SWV at Au-macro



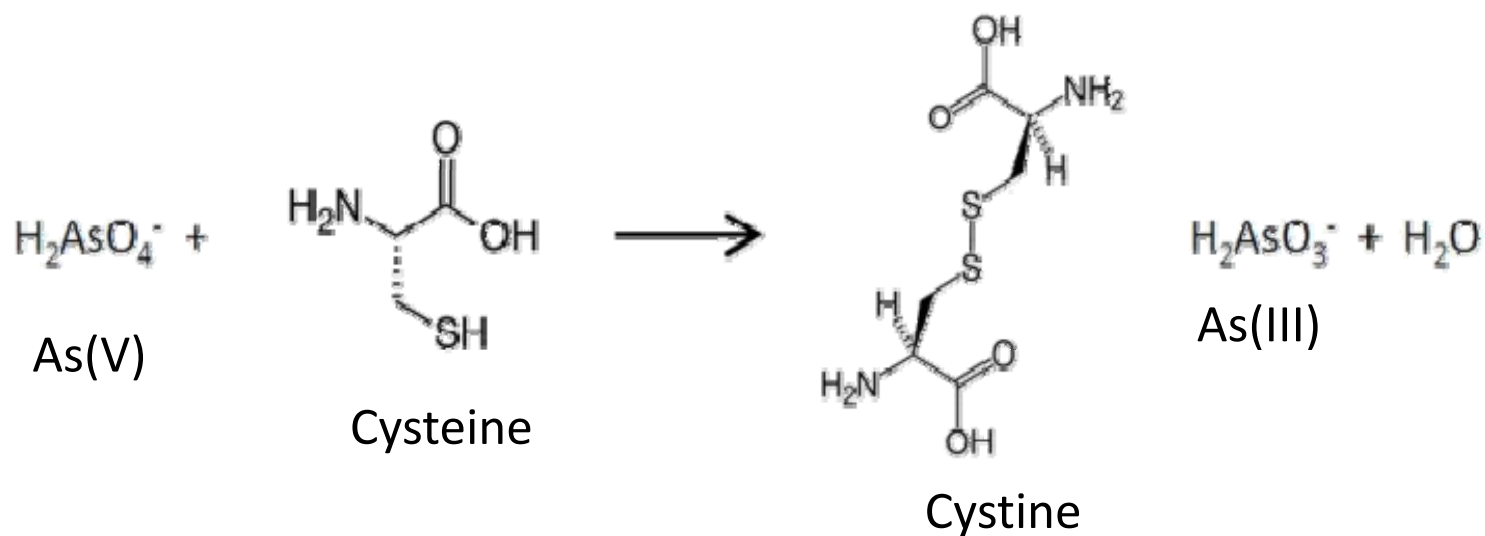
Deposition at -0.4 V for 120 s



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INORGANIC As SPECIATION



Analytical procedure:

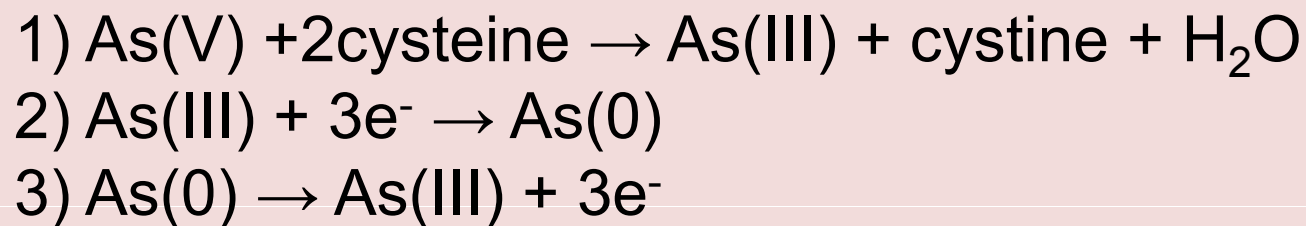
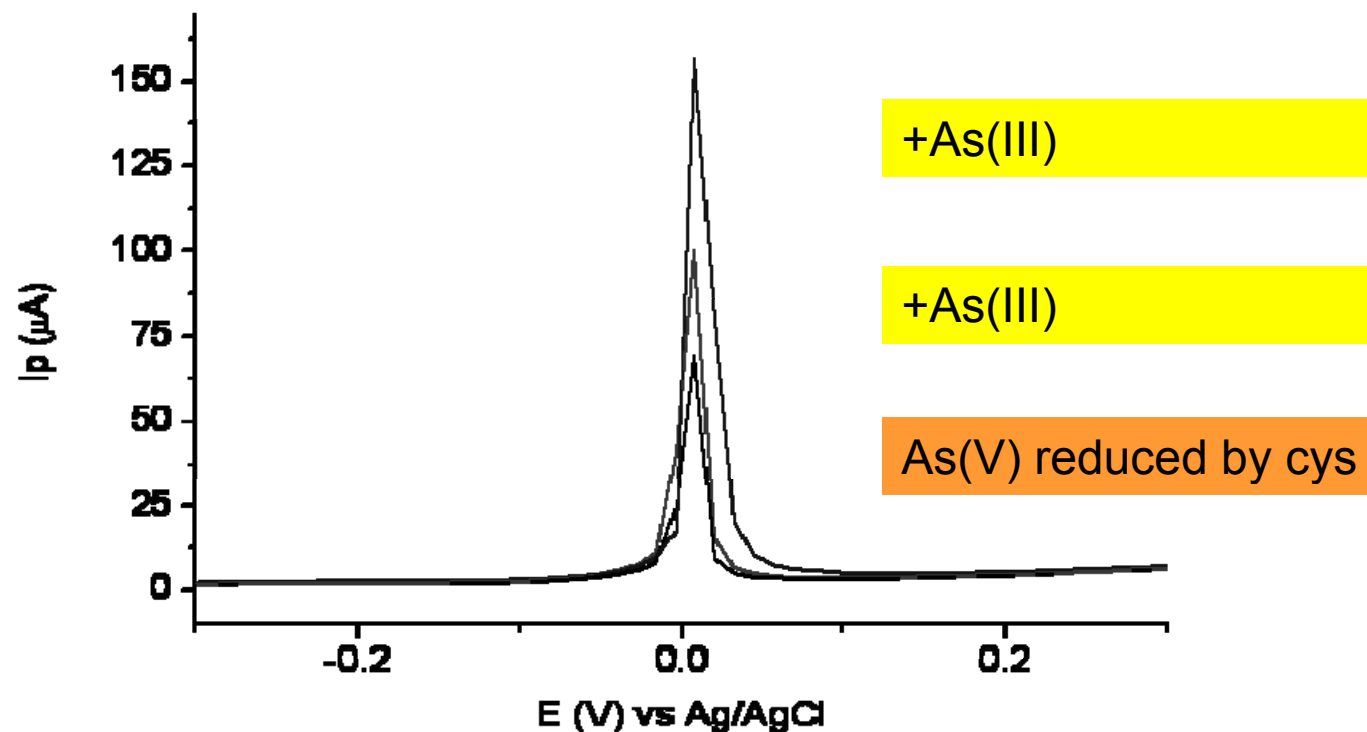
- Reduction in not acidified solution with 4.9 mM cysteine
- 80°C for 30 min.



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Reductive determination of As (V)





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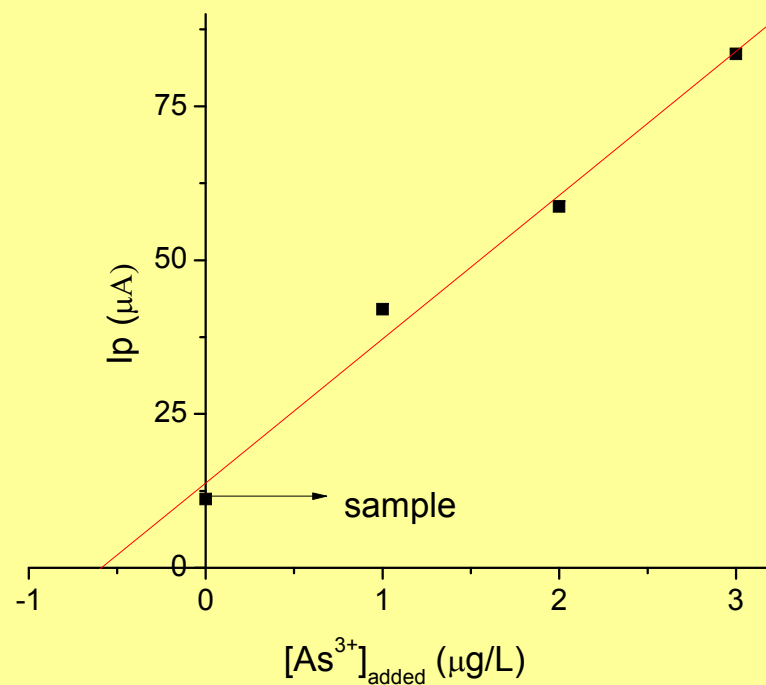
Analytical performances: accuracy

CASS-4

(near shore seawater) diluted 1:1

As certified $1.11 \pm 0.16 \mu\text{gL}^{-1}$

As found: $1.18 \pm 0.06 \mu\text{gL}^{-1}$





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Analytical performances: comparison between NEE and Au-macro (deposition time 180 s)

	NEE	Au-macro
Detection limit ($3\sigma_b$ /m)	0.005 $\mu\text{g/L}$	0.75 $\mu\text{g/L}$
Linearity range	0.2 - 6 $\mu\text{g/L}$	20 – 150 $\mu\text{g/L}$
Sensitivity (m)	65. 6 $\mu\text{A L} / \mu\text{g}$	5.5 $\mu\text{A L} / \mu\text{g}$
Background noise (σ_b)	0.11 μA	1.38 μA

Problem

NEEs are easily saturated (very small active area).
It is required to extend their linearity range.



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2° part OUTLINE

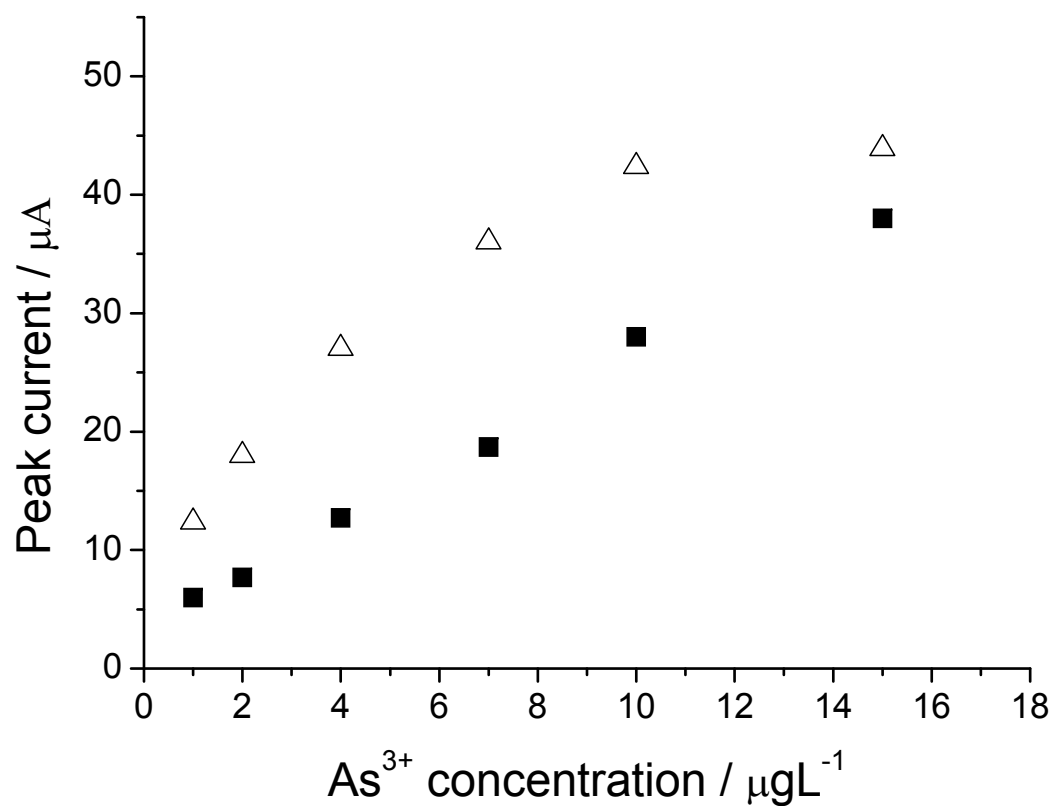
3. From 2D to 3D-NEEs
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Analytical performances: effect of the deposition time on the linearity range

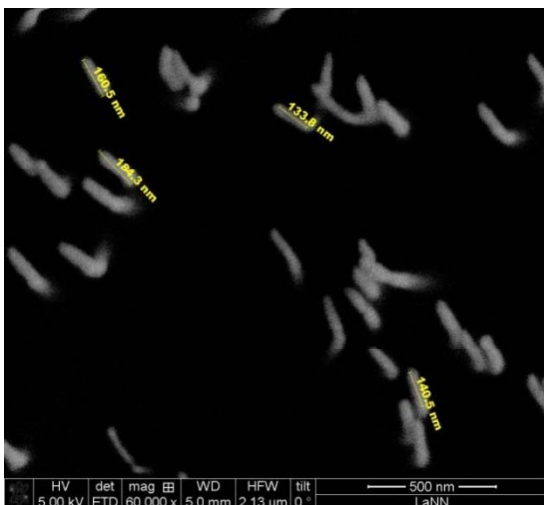




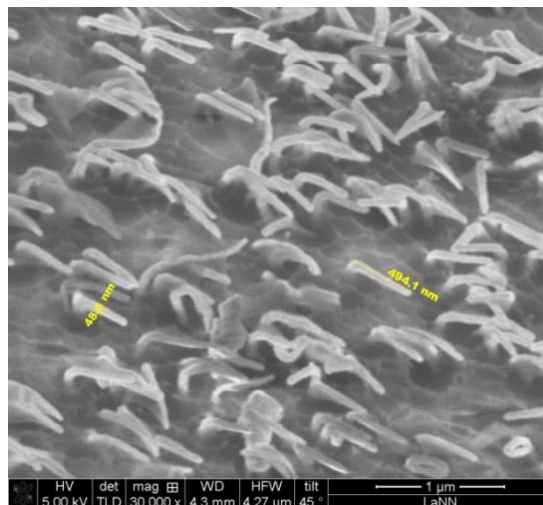
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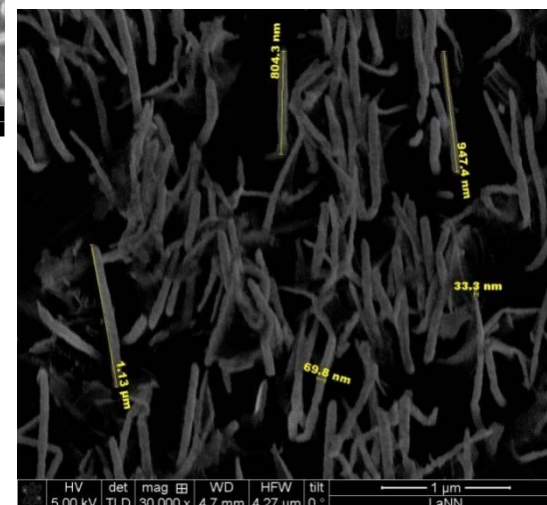
PROBLEM: easy saturation of the NEE surface
SOLUTION: OXYGEN PLASMA ETCHING



1 minute



5 minutes



10 minutes

Increase of active area with O₂-plasma etching

Treatment duration (min)	Nanofiber lenght (μm)	$A_{(3D-NEE)} / A_{(2D-NEE)}$	$A_{(ACTIVE)} / A_{(GEOMETRIC)}$
0	0	1	0.004
1	0.15	20	0.089
5	0.5	67	0.287
10	1	133	0.569

By a controlled increase of the A_{act}/A_{geom} the S/N decreases therefore a compromise between these aspects is required.



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O_2 -plasma etching As(III) response at 3D-NEEs

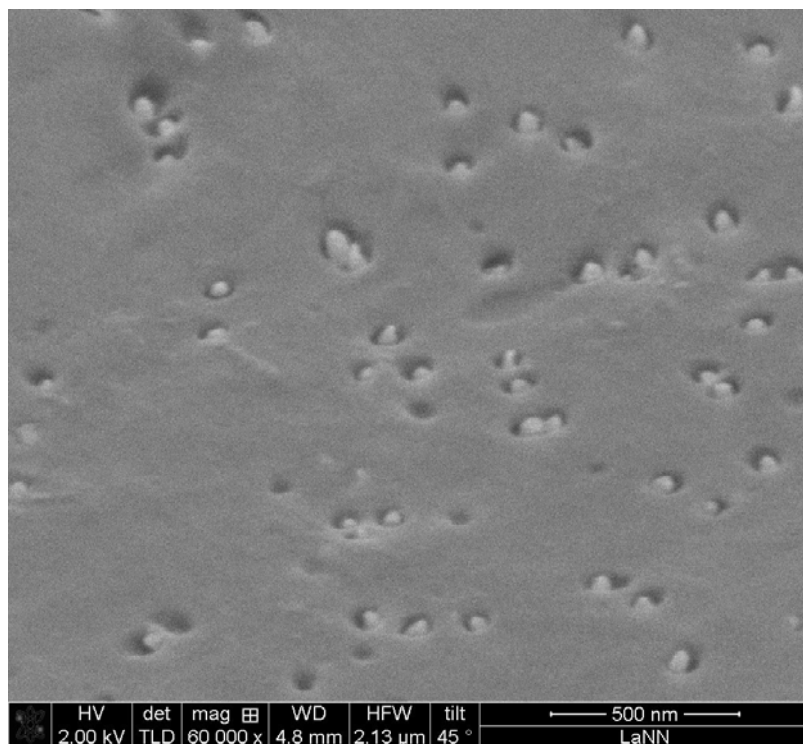
NEE	t_{etching} (min)	t_{dep} (sec)	LR ($\mu\text{g/L}$)	m ($\mu\text{A}\cdot\text{L}/\mu\text{g}$)	DL ($\mu\text{g/L}$)
NEE 528	1	180	2-15	1.54	0.060
NEE 529	1	180	1-20	1.32	0.082
NEE 534	5	180	5-40	3.22	0.079
NEE 535	5	180	2-30	3.40	0.050
NEE 507	10	180	5-40	5.73	0.073
NEE 506	10	180	5-40	5.98	0.064

Increasing sensitivity

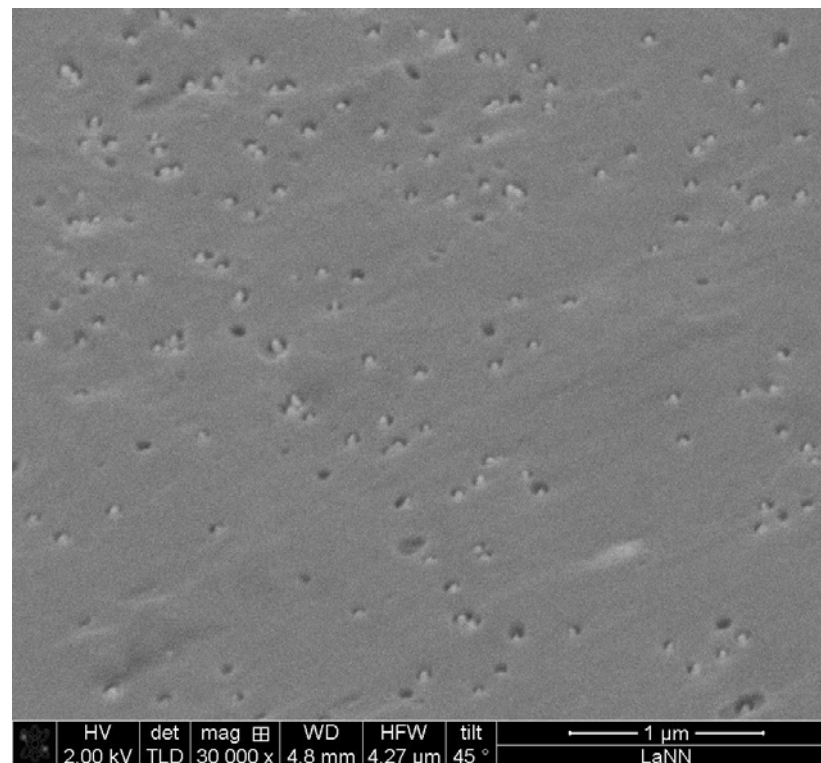




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Chemical etching
 $\text{CH}_2\text{Cl}_2 : \text{EtOH}$
1 : 9



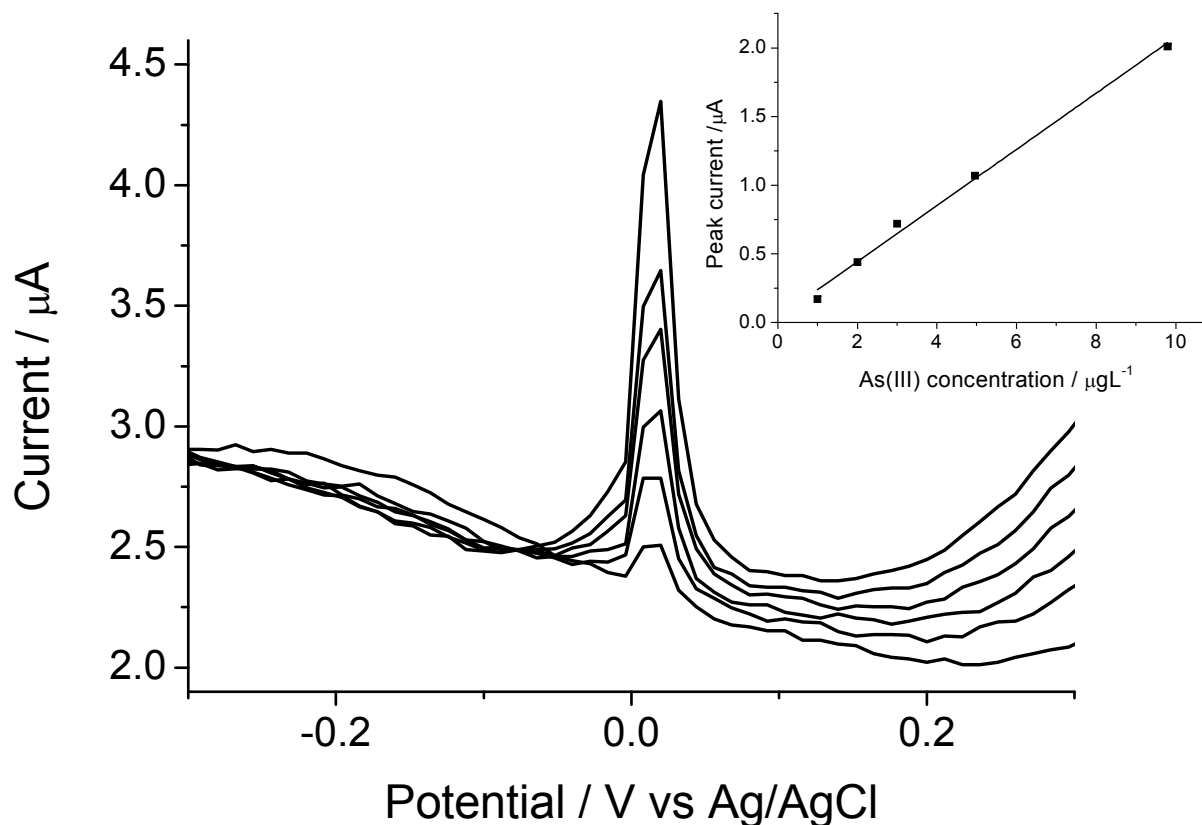
De Leo et al. *Electroanalysis*, 19 (2007) 227



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Chemical Etching time: 5s As(III) response at 3D-NEEs



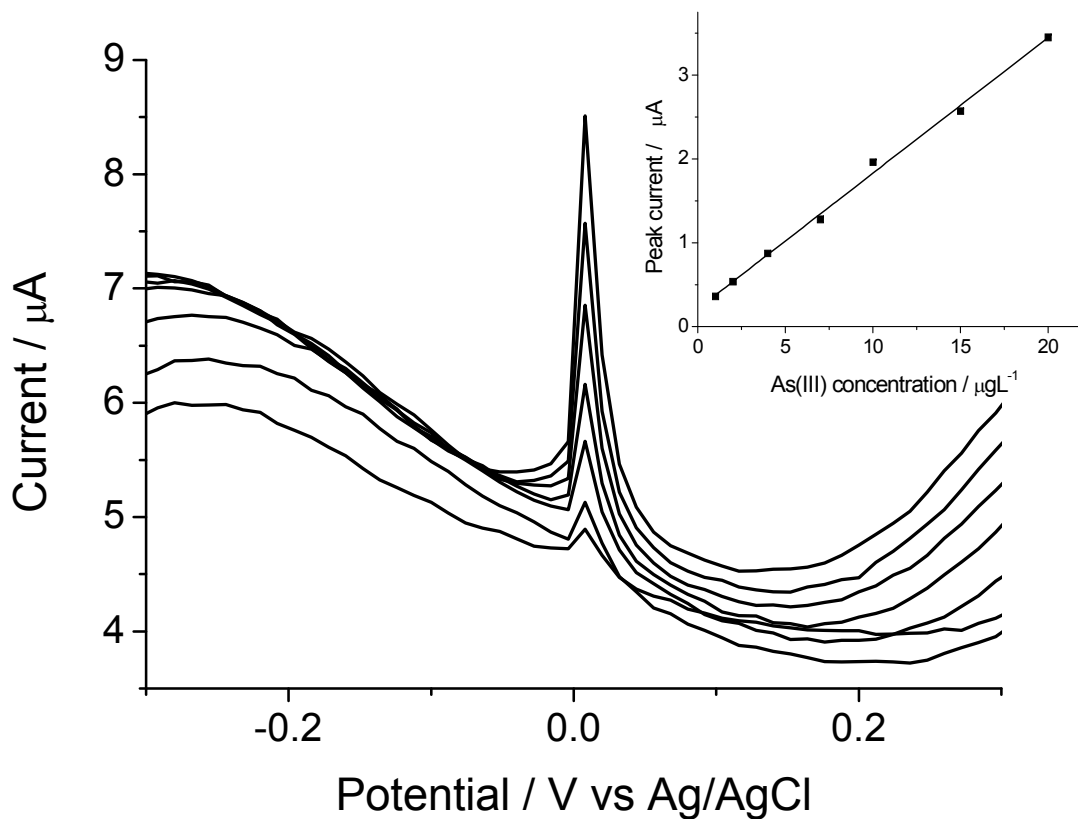
NEE	t_{etching} (sec)	t_{dep} (sec)	LR ($\mu\text{g/L}$)	m ($\mu\text{A}\cdot\text{L}/\mu\text{g}$)	DL ($\mu\text{g/L}$)
NEE 601	5	180	1-5	0.102	0.14



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Chemical Etching time: 20s As(III) response at 3D-NEEs



NEE	t_{etching} (sec)	t_{dep} (sec)	LR (μg/L)	m (μA·L/μg)	DL (μg/L)
NEE 601	5	180	1-5	0.102	0.14
NEE 606	20	180	1-20	0.161	0.08

Increasing sensitivity



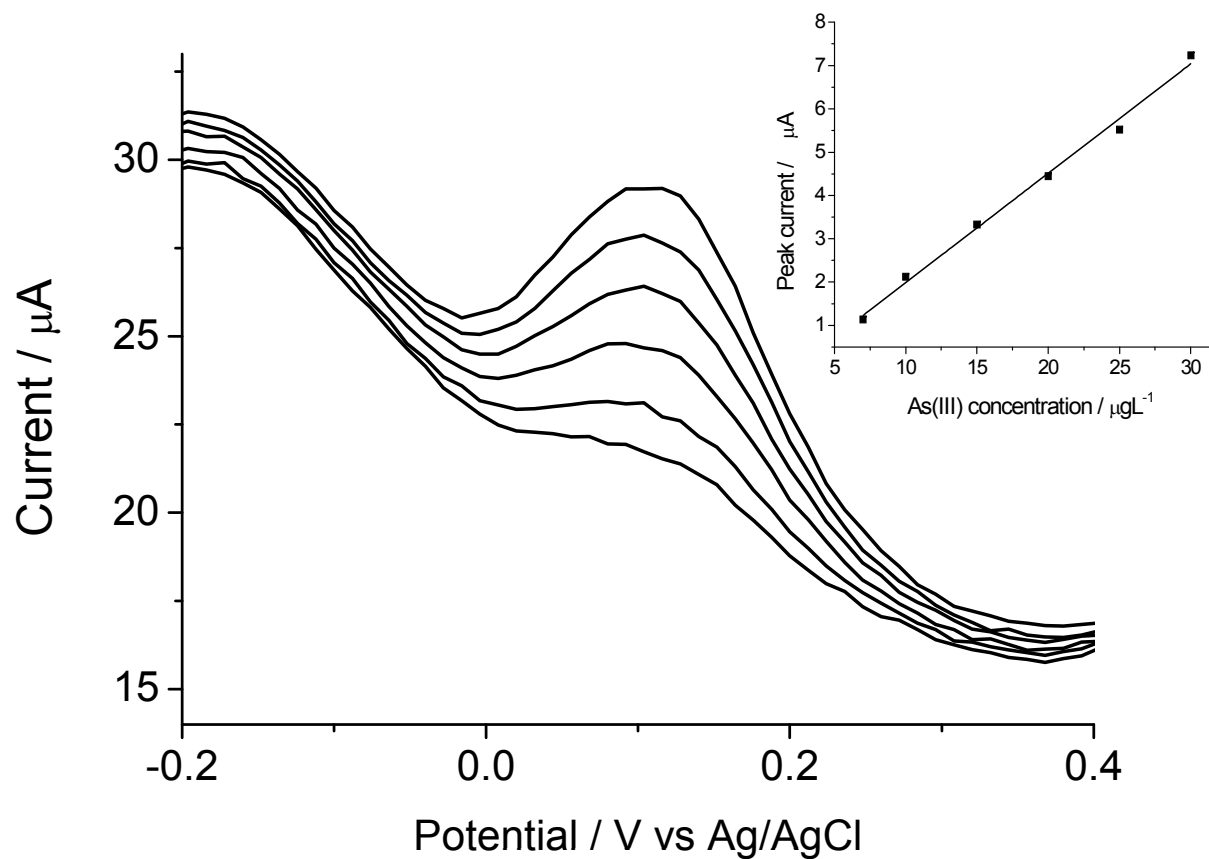


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Chemical etching

Etching time: 30s





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Chemical etching As(III) response at 3D-NEEs

NEE	t_{etching} (sec)	t_{dep} (sec)	LR ($\mu\text{g/L}$)	m ($\mu\text{A}\cdot\text{L}/\mu\text{g}$)	DL ($\mu\text{g/L}$)
NEE 601	5	180	1-5	0.102	0.14
NEE 606	20	180	1-20	0.161	0.08
NEE 602	30	180	5-30	0.292	0.11

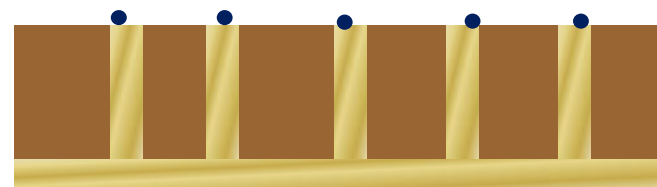
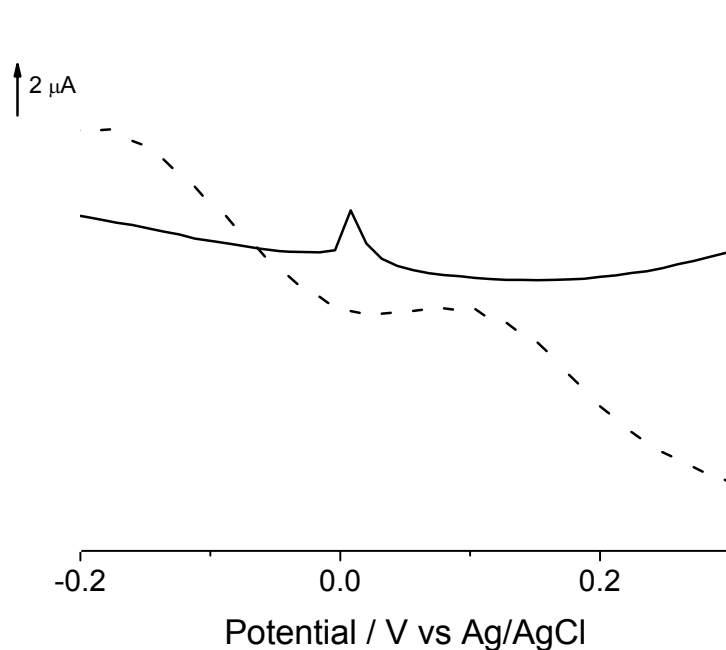
Increasing sensitivity
↓



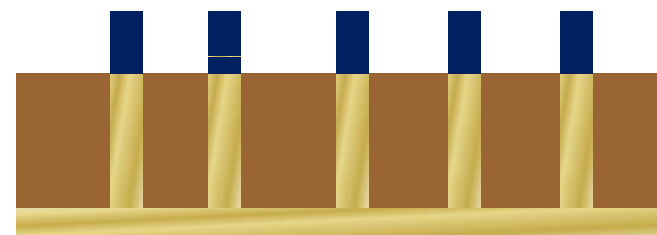
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INFLUENCE OF ETCHING ON THE STRIPPING PEAK POTENTIAL



On un-etched NEE, As nuclei are deposited



On 3D-NEE thin As film is deposited

NEE 606-3D at two different etching time in solution of 10 ppb As (III)

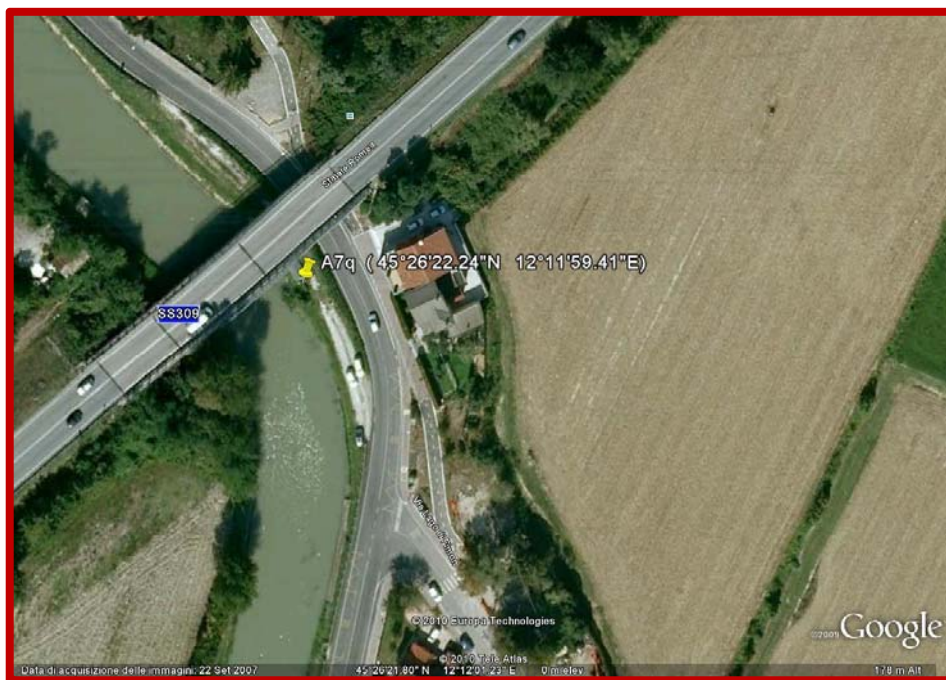


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REAL SAMPLES

Sampling





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ANALYTICAL PROCEDURE

SAMPLING AND FILTERING (0.45µm)

~~REDUCTION WITH SOLID CYSTEINE~~

DILUTION AND ACIDIFICATION (pH 0.8 in HCl)

ANODIC STRIPPING VOLTAMMETRY AT 60 SEC. DEP. TIME

No peak detected

3 STANDARD ADDITIONS OF As(III)

ANODIC STRIPPING VOLTAMMETRY
AT 120 or 180 SEC. DEP. TIME

3 STANDARD ADDITIONS OF As(III)

**TOTAL INORGANIC
As CONCENTRATION**
(Tot_{inorg} As)

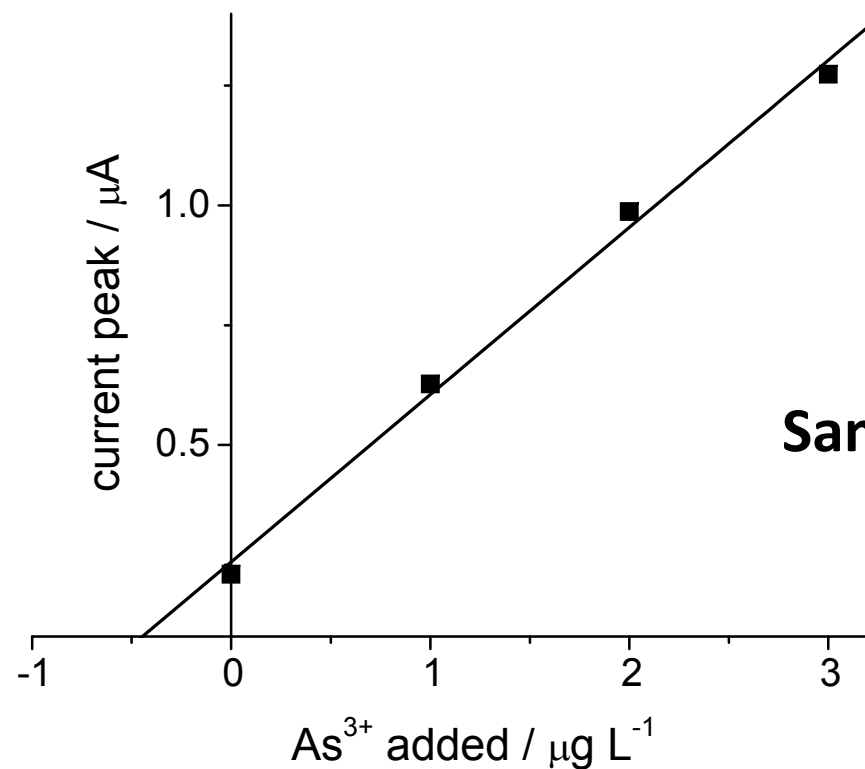
$$\text{As(V)} = \text{Tot}_{\text{inorg}} \text{As} - \text{As(III)}$$



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REAL SAMPLES WITH 3D-NEE



Sample diluted 1:3

3D-NEE value = 2.9 μg/L

ICP-MS value* = 2.7 μg/L

*** = ARPAV with ICP-MS following UNI EN ISO 17294-2:2005**



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REAL SAMPLES

(river from Venice Lagoon basin)

3D-NEE reproducibility

T dep	Dilution	Inorg As ($\mu\text{g/L}$)	# NEE	As(III) in diluted samples ($\mu\text{g/L}$)
180	1:3	3.1	NEE 616 3D	1.1
180	1:3	3.3	NEE 615 3D	1.2
120	1:3	3.1	NEE 614 3D	1.0

3D-NEE value = $3.2 \pm 0.2 \mu\text{g/L}$

ICP-MS value = $3.2 \pm 0.1 \mu\text{g/L}$

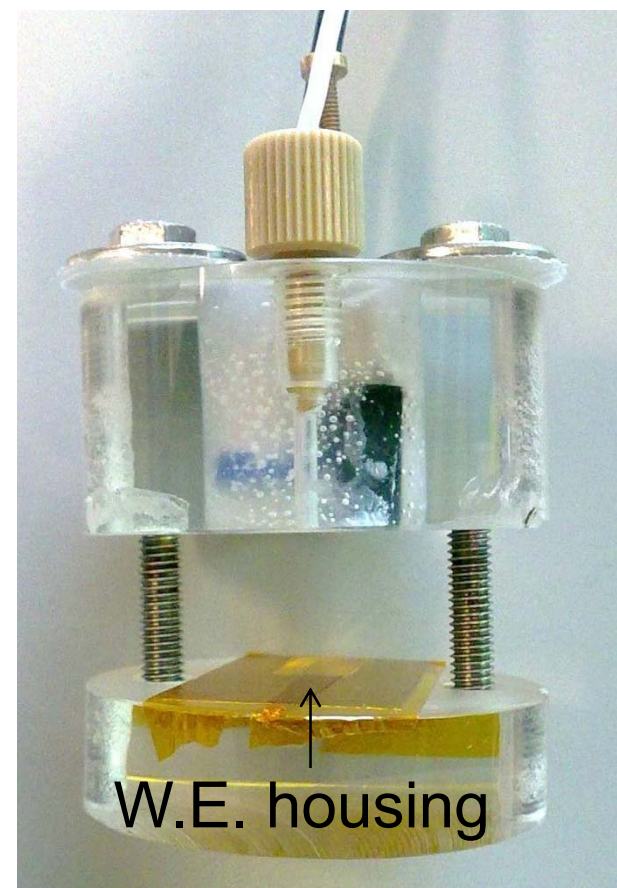
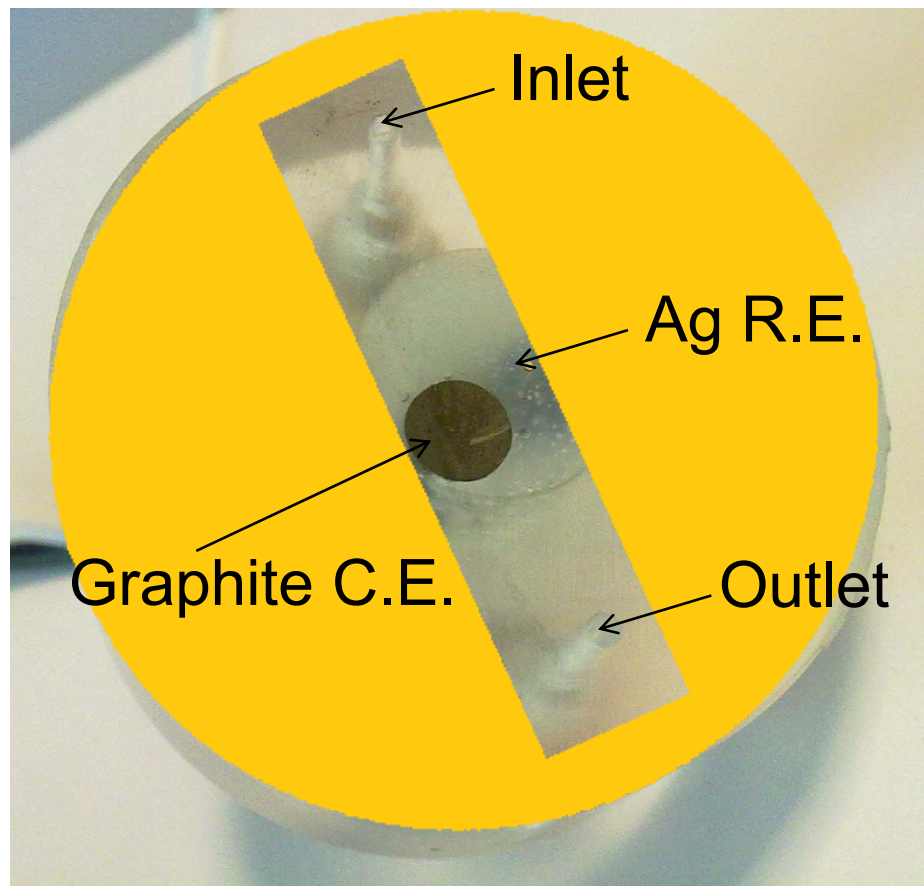


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FLOW ANALYSIS

preliminary results





The diagram illustrates the electrochemical cell setup for the reduction of As(III) to As(0). The cell contains three electrodes: Graphite C.E. (Cathodic Electrode), Ag R.E. (Reference Electrode), and NEE W.E. (Working Electrode). The electrodes are connected to a POTENTIOSTAT. A legend indicates that red circles represent As(III) and blue circles represent As(0).



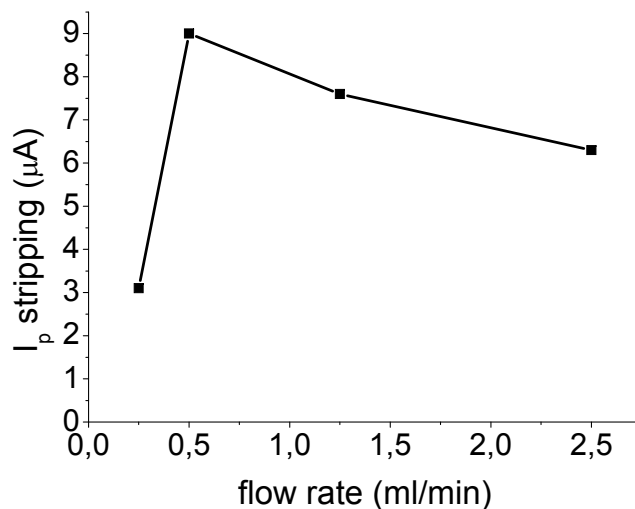
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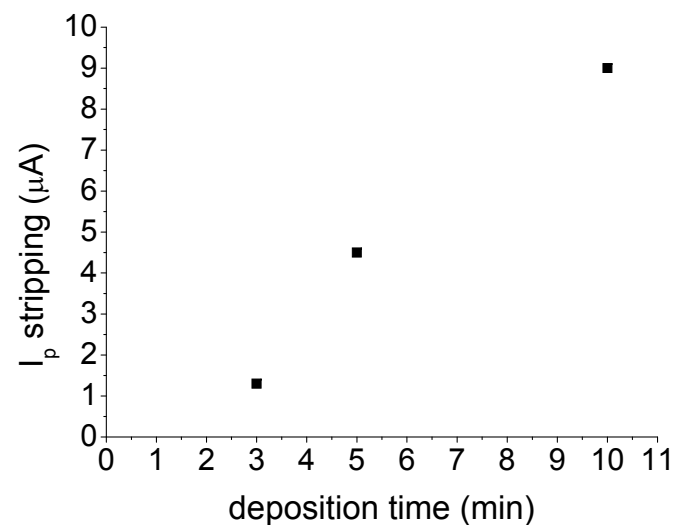
FLOW ANALYSIS

preliminary results

INFLUENCE OF THE FLOW RATE



INFLUENCE OF THE DEPOSITION TIME



First steps towards the optimization of the flow cell:
determination of the optimal flow rate
And
correlation between stripping current and deposition time.

Experiments performed in 1 ppm As solution.



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CONCLUSIONS

- NEEs showed good results in the determination of trace As(III) through SW-ASV.
- Solid cysteine was used as reducing agent for As(V) allowing us to detect total inorganic arsenic.
- Through plasma or chemical etching of NEEs the linearity range of the analytical response was extended.
- 3D-NEEs can be applied for the successful determination of inorganic arsenic in river water and natural waters.

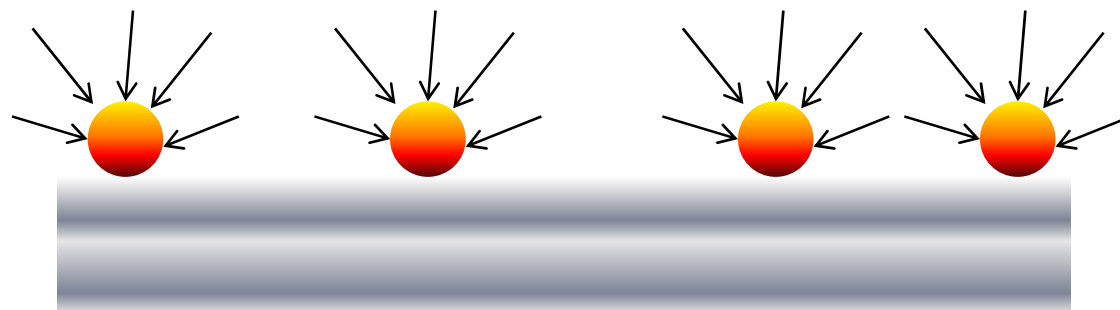


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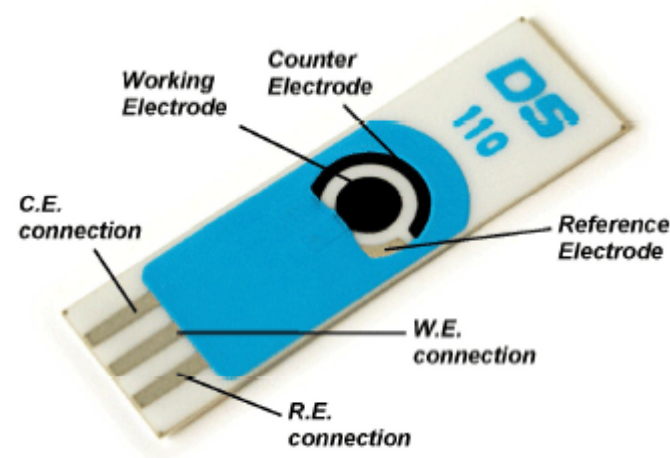
Prospects

develop cheap and disposable electrodes and devices for automatic As determination



Arrays of Nanoparticles $\cong$ Arrays of Nanoelectrodes

- Screen-printed electrodes modified with Gold NanoParticles
- Developing a batch analyzer employing a flow cell





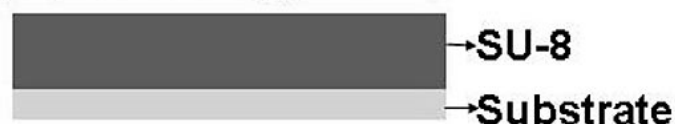
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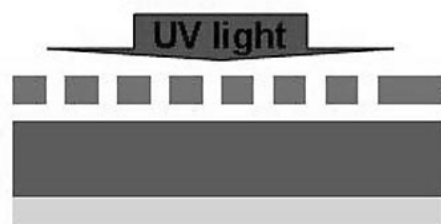
Prospects

Towards pyrolyzed photoresist nanoelectrodes arrays to combine carbon nanostructures with gold modification.

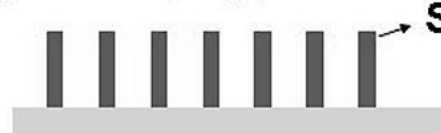
(a) Spin-coating photoresist



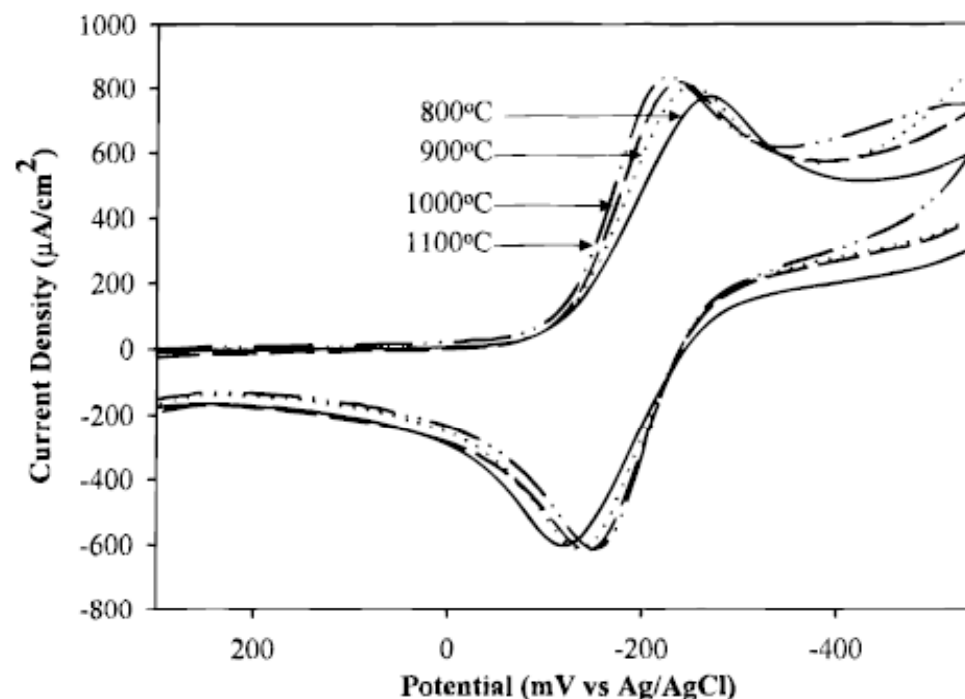
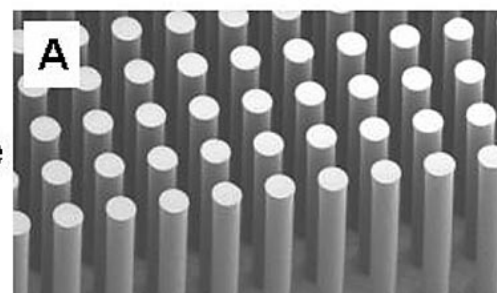
(b) UV exposure



(c) Developing



(d) pyrolysis





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Regione Veneto:

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EC-Interreg: Trans2 Care

Thank you !!!!

